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JUL 02 2004

OFFICIAL

Patent

Customer No.: 31561
Docket No. 11437-US-PA
Application No.: 10/604,835

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Applicant : Liu et al.
 Application No. : 10/604,835
 Filed : 2003/08/21
 For : METAL SILICIDE STRUCTURE AND METHOD OF
 FORMING THE SAME
 Art Unit : 2811
 Examiner : VU, QUANG D

TRANSMITTAL LETTER

002-1-703-872-9306

(Via fax: 3 pages, followed by confirmation copy via courier)

Assistant Commissioner for Patents
Arlington, Virginia 22202

Dear Sirs,

In response to the Office Action dated June 15, 2004, please find the relevant paper in response to paper No. 060204. Following the fax transmission, a hard copy via courier will also be forwarded to the Office.

Enclosed documents via courier will include:

- Response to Restriction Requirement in (1) pages
- Fax confirmation report
- Prepaid return postcard

I believe that no fee is incurred. However, the Commissioner is authorized to charge any fees required in connection with the filing of this paper to account No. 50-2620 (Order No.: 11437-US-PA)

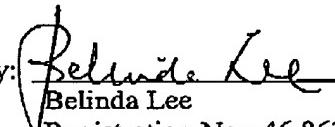
Thank you for your assistance in the subject matter. If you have any questions, please feel free to contact me.

Patent

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Docket No. 11437-US-PA
Application No.: 10/604,835

Respectfully Submitted,
JIANQ CHYUN Intellectual Property Office

Date: July 2, 2004

By: 
Belinda Lee
Registration No.: 46,863

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FORMING THE SAME
Art Unit : 2811
Examiner : VU, QUANG D

RESPONSE TO RESTRICTION REQUIREMENT

ASSISTANT COMMISSIONER FOR PATENTS
Arlington, VA 22202

Dear Sirs,

In response to the Office Action, mailed on June 15, 2004, Applicant would like to elect Group I, claims 1-10, drawn to a method for forming a metal silicide layer, classified in class 438, subclass 682. Please cancel Group II, claims 11-14, drawn to a metal silicide structure, classified in class 257, subclass 388 without waiver, prejudice or disclaimer.

Thank you for your assistance in the subject matter. If you have any questions, please feel free to contact me.

Respectfully Submitted,
JIANQ CHYUN IP Office

Date: July 2, 2004

By: Belinda Lee
Belinda Lee
Registration No.: 46,863

Please send future correspondence to:

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